

Patterning of V₂O₅ nanowires via Langmuir-Blodgett technique combined with μ-contact printing

<u>박재현</u>, 신건철, 하정숙* 고려대학교 화공생명공학과

* E-mail: jeongsha@korea.ac.kr

We devised facile method to pattern V₂O₅ nanowires onto hydrophobic as well as hydrophilic substrates via Langmuir-Blodgett (LB) and Langmuir-Shaeffer (LS) techniques combined with μ-contact printing. It is easy to disperse V₂O₅ nanowires into water, but hard to float on water surface. Use of dioctadecyldimethylammonium bromide (DODAB) as surfactant made V₂O₅ nanowires float on water surface without any chemical treatments. The LB isotherm data and the AFM measurements show that the composite films of DODA+V₂O₅ nanowires are formed on water surface. It is considered that the electrostatic interactions between the DODA⁺ and negatively charged V₂O₅ nanowires in the acidic aqueous solution makes the stable composite film on water surface. LB method enables the transfer of highly ordered conformal DODA V₂O₅ nanowire composite films onto any substrates regardless of the hydrophobicity of the substrate. AFM study shows that V_2O_5 nanowires are aggregated under the DODA⁺ islands whose heights are ~ 5nm. Transfer of the well-ordered LB film of DODA⁺/V₂O₅ nanowires onto the patterned poly dimethylsilioxane (PDMS) stamp and subsequent stamping onto the 3-aminopropyltriethoxysilane-treated SiO₂ substrate resulted in the fabrication of V₂O₅ nanowire patterns. Only DODA⁺ islands can be selectively removed by rinsing with DI-water from transferred patterns of DODA+V2O5 composite film without deformation. Infrared spectroscopy, DSC/TPA, and EDX-SEM measurements also supported the transfer mechanism of the V₂O₅ nanowires.